

**REMARKS**

Applicants file this Amendment along with a Request for Continued Examination (RCE). As indicated in the RCE Transmittal Form, Applicants request that the Examiner consider this Amendment as well as the Amendment After Final filed on September 4, 2003. Claims 1-5, 13, and 14 are currently pending in the application.

In addition to the Amendment After Final filed on September 4, 2003, this Amendment amends independent claim 1 further. As amended, independent claim 1 recites "[a]n etching method for etching an etching target film formed on an SiO<sub>2</sub>" and that "said etching target film is an organic film containing Si formed on an SiO<sub>2</sub> film." Other than these amendments to independent claim 1, the pending claims are the same as those presented in the Amendment After Final filed on September 4, 2003. Accordingly, for the reasons similar to the those explained in the Remarks section of the Amendment After Final filed on September 4, 2003, Applicants respectfully submit that all pending claims are in condition for allowance.

Please grant any extensions of time required to enter this response and charge any additional required fees to our Deposit Account No. 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,  
GARRETT & DUNNER, L.L.P.

Dated: December 2, 2003

By: 

Chi H. Kang  
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